

RESEARCH PAPER

15 GHz quadrature voltage controlled oscillator in 130 nm CMOS technology

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This paper reports a 15 GHz quadrature voltage controlled oscillator (QVCO) designed in a 130 nm CMOS technology. The phase noise performance of the QVCO and of a phase locked loop (PLL) where the QVCO was inserted were compared with the literature and with telecom standards and commercial products for broadcast satellite applications.

Keywords: DVBS, CMOS, QVCO, PLL, design, phase noise

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I. INTRODUCTION

The Ku-band is very interesting for mass market applications as satellite broadcasting and microwave link [1, 2]. In a Ku-band satellite receiver usually the signal picked-up by the dish antenna is amplified by a low noise amplifier (LNA) designed with compound semiconductor HEMT (high electron mobility transistor) and the local oscillator is a dielectric resonator oscillator. Both these facts do not allow for the fabrication of a monolithic receiver. Efforts have been made, in order to fabricate a monolithic satellite receiver using silicon-based technologies. Next Experience (NXP) commercializes a low noise block (LNB) integrating on the same die the down-conversion mixer, the VCO, and the PLL (phase locked loop). The chip is designed using a state-of-the-art SiGe Bipolar CMOS (BiCMOS) technology. It is worth here noticing that bipolar technologies were also used in the past to design a monolithic digital video broadcasting satellite (DVBS) receiver [3].

Recently, efforts have been also made to design a satellite receiver using CMOS technologies [1, 2]. In [1] the design was focused on the receiver chain only (LNA and mixer) while in [2] the whole LNB was addressed. In both the cases, the adopted technology was a 180 nm CMOS using a 1.8 V supply.

In all these efforts the DVBS receiver exhibits a superheterodyne block diagram constituted by two blocks: the LNB and the In-Phase/Quadrature (I/Q) tuner. The LNB downconverts the signal from the satellite to the IF frequency. The IF composite signal is then solved in its I and Q components by the tuner. The tuner is usually fabricated in a low-power CMOS technology while for the high-frequency LNB the only silicon-

based commercial product is, at the best knowledge of the authors, the TFF1004HN chip fabricated using a 110 GHz f_T SiGe BiCMOS technology [4].

In the present paper a quadrature voltage controlled oscillator (QVCO) in a 130 nm CMOS technology is investigated having in mind the idea of replacing the previously sketched out traditional superheterodyne architecture with a direct conversion architecture where the LNB receives the composite signal from the satellite and provides at the output in one step the I and Q bit stream at the base band. The QVCO is indeed usually the preferred solution to generate in-quadrature signals with respect to poly-phase filters, ring oscillators, or frequency dividers. In the design of the QVCO attention should be paid to the phase noise, which is a very stringent specification for the satellite broadcasting, because of the use of Amplitude and Phase Shift Keying (APSK) modulation schemes that make the constellation round and therefore prone to suffer from cycle slips if the phase noise of the local oscillator is too high.

In particular, the central frequency was fixed at 15 GHz, to evaluate the technology capabilities not only for the ground receiver (e.g. in the DVBS the down-link frequency band is 10.7–12.75 GHz) but also for the on satellite receiver (e.g. in the DVBS the up-link frequency band is 12.9–18.4 GHz).

II. CIRCUIT DESIGN

Figure 1 depicts the schematic of the designed QVCO. The circuit was biased without current mirror for sake of phase noise minimization [5]. In addition, the lack of a current mirror allows to reduce the power consumption [6] and to avoid the introduction of a automatic amplitude control circuit [7].

All the transistors were designed multi-finger and with a minimum channel length (0.13 μm). To get an equivalent admittance of the coupled pairs negative enough to compensate for the losses and robust enough against the fabrication tolerances, the p-channel transistors of coupled pairs were

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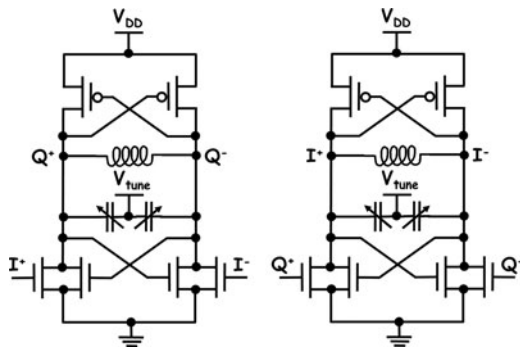


Fig. 1. Schematic of the designed QVCO.

designed wider than the n-channel ones: the gate width of the p-channel transistors was fixed equal to 56 μm and the gate width of the n-channel transistors was fixed equal to 10 μm . For sake of good locking capability and of flicker noise minimization, the coupling n-channel transistors width was fixed equal to 16 μm .

The tank was designed using a single octagonal coil differential inductor resonating with the parasitic capacitances. A compact model as that described in [8] was extracted from electromagnetic simulations carried out both with the 2D 1/2 electromagnetic simulator Momentum by Agilent Technologies and with the 3D electromagnetic simulator by CST. The inductor exhibits an inductance of about 290 pH and a maximum quality factor in the range of 27. It is worth pointing out that these values of inductance and quality factor are very close to those recently claimed in [9] for a 65 nm CMOS LC VCO working in the Ku-band.

To obtain tuning capability, two 20-finger accumulation MOS varactors with a minimum gate length of 350 nm were introduced [10].

III. EXPERIMENTAL RESULTS

Figure 2 shows the microphotograph of the fabricated prototype. In the middle of the chip are visible the two inductors of the VCO core. In the microphotograph are also visible the two buffers to drive the load of the instruments. Under an experimental point of view, the use of the buffers is mandatory, in order to perform reliable measurements. Without buffers, the losses of the external load connected to the circuit during the characterization can degrade the VCO performance or,

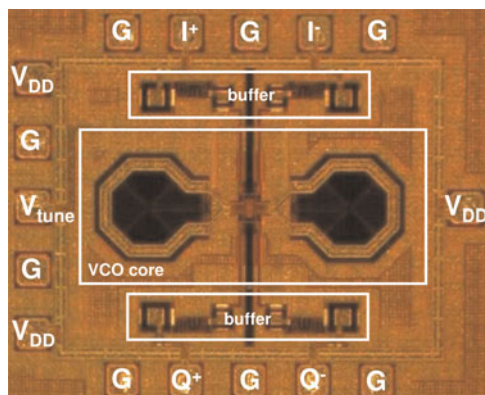


Fig. 2. Microphotograph of the fabricated QVCO.

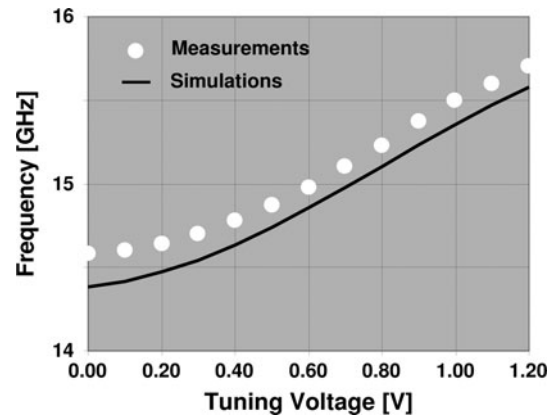


Fig. 3. Comparison between measured and simulated frequency dependence on the tuning voltage.

on the other hand, high-Q lines connected to the pads via the coplanar probes and coaxial cables can improve the VCO performance.

The GSGSG pads for the differential in-phase (I^+ , I^-) and in quadrature (Q^+ , Q^-) RF output signals are visible on the top and on the bottom of the chip, respectively. At the left side the pad GSG pad for the tuning voltage (V_{tune}) is visible. Eventually, three pads for the supply (V_{DD}) are distributed along the pad ring. The chip size is $900 \times 1100 \mu\text{m}^2$, pads enclosed.

The differential output signals were made available to the single-ended input of the Agilent E4408B spectrum analyzer using a wideband Anaren 30070 hybrid.

Figure 3 reports the output frequency variation with the tuning voltage. A difference less than 1.3% between simulations and measurements was obtained on the whole tuning range. The carrier frequency (f_0) goes from 14.6 to 15.8 GHz for V_{tune} ranging between 0 and 1.2 V corresponding to a tuning range of 7.4%. The QVCO delivers about -20 dBm on a 50 Ω load and it sinks 9.4 mA from a 1.2 V supply.

Phase noise measurements were carried out for V_{tune} ranging between 0 V and 0.6 V using an Agilent E5500 phase noise meter. Figure 4 shows the measured phase noise for $f_0 = 14.6$ GHz. The QVCO exhibits a phase noise of -106 dBc/Hz at the offset frequency (Δf) of 1 MHz. This value is very close to the -107 dBc/Hz (at 1 MHz from a 10.7 GHz carrier) recently claimed for the VCO used in the PLL of a monolithic Ku-band receiver [2]. For other values of applied V_{tune} the phase noise did not change in agreement with simulations.

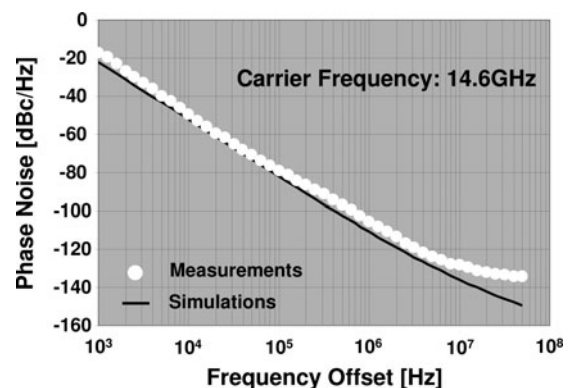


Fig. 4. Comparison between measured and simulated phase noise.

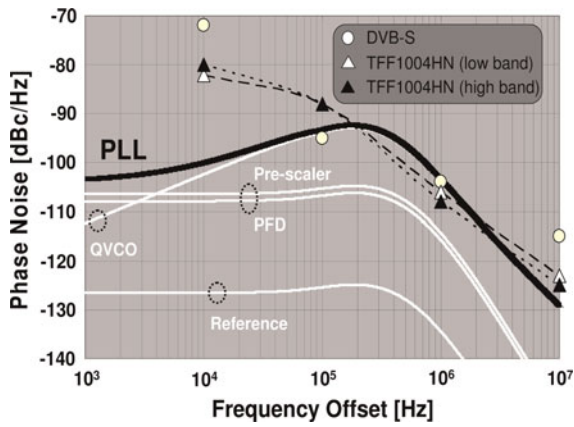


Fig. 5. Simulated PLL phase noise (black curve) together with the single contributions of the PLL building blocks (white lines) compared with the DVBS standard and the commercial product TFF1004HN.

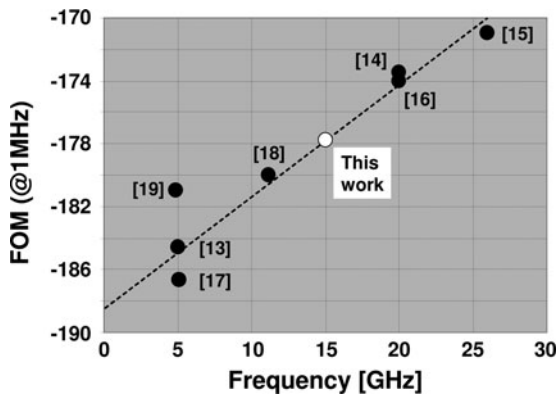


Fig. 6. FOM versus oscillation frequency. Comparison between the QVCO reported in the present work (white dot) and others VCOs reported in the literature (black dots). Technology is 130 nm CMOS in all cases.

IV. DISCUSSION

Since the VCO has to be employed in a PLL, the measured phase noise depicted in Fig. 4 has been therefore inserted in a PLL simulation carried out with Matlab. The noise contributions of the pre-scaler, of the phase and frequency detector, and of the reference have been set to typical values. The loop filter was designed so that to obtain a PLL bandwidth of 400 kHz and a phase margin of 60°. Figure 5 shows the simulated phase noise (black curve). The white lines are the contributions of the single building blocks.

The PLL phase noise is very close to the DVBS phase noise specifications (open circles) at the offset frequencies of

100 kHz and 1 MHz [11]. The simulated phase noise is a higher than standard limit in the offset frequency range 100 kHz–1 MHz. The simulated phase noise is also comparable with the phase noise exhibited by the TFF1004HN commercial product [4] and it is better for offset frequencies lower than 100 kHz. As further discussion about Fig. 5, it is worth pointing out that the phase noise and, in particular, the tuning range specifications have to be addressed by introducing a switched capacitor bank in the VCO topology during the design of the final PLL.

Eventually, the performance of the fabricated QVCO has been compared with other 130 nm CMOS VCOs reported in the literature through the following figure-of-merit (FOM) that allows for a comparison normalized with respect to the power and the frequency [12]:

$$FOM = L(\Delta f) - 20 \log\left(\frac{f_0}{\Delta f}\right) + 10 \log\left(\frac{P_{DC}}{1 \text{ mW}}\right) \quad (1)$$

where $L(\Delta f)$ is the phase noise at Δf , and P_{DC} is the dissipated DC power (Table 1).

Figure 6 plots the FOM versus the oscillation frequency. The QVCO reported on the present work is well aligned with the other VCO’s trend extracted from the literature.

A comparison with Ku-band cross-coupled VCO designed in 90 nm, see for instance [20], or 65 nm, see for instance [21], CMOS technologies does not point out a remarkable improvement in the phase noise even if these technologies are more expensive than the 130 nm CMOS adopted in the present work. The adoption of a 90 nm/65 nm CMOS technology may help with reducing the dissipated power and therefore with improving the FOM but not the phase noise in itself.

V. CONCLUSIONS

A 130 nm CMOS QVCO exhibiting a central frequency of 15 GHz has been demonstrated. The phase-noise-related FOM is well aligned with other 130 nm CMOS VCOs reported in the literature. In particular, the comparison with other CMOS VCOs claimed in the literature for Ku-band satellite receiver, with the DVB-S standard, and with commercial products implemented in SiGe BiCMOS technologies suggests that the 130 nm CMOS technology can be evaluated with interest for the design of a DVB-S satellite receiver front-end.

It is authors opinion that the main contribution of the present paper is not in the circuit topology in itself, that was already used in the past for a plant of applications, but rather in having provided demonstration that a bulk standard (e.g. not SOI) 130 nm CMOS technology can be employed to

Table 1. Comparison with other 130 nm CMOS VCOs reported in the literature.

	Technology (μm)	Frequency (GHz)	Tuning range (%)	Supply (V)	Power (mW)	Phase noise (dBc/Hz)	FOM (dBc/Hz)
[13]	CMOS 0.13	5	20	1.2	5.28	-117 at 1 MHz	-185
[14]	CMOS 0.13	20	10.2	n.a.	32	-102 at 1 MHz	-173
[15]	CMOS 0.13	26	3.1	1.35	24	-96 at 1 MHz	-171
[16]	CMOS 0.13	20	12	n.a.	20	-101 at 1 MHz	-174
[17]	CMOS 0.13	5.1	5.26	1.2	3.7	-118 at 1 MHz	-187
[18]	CMOS 0.13	11.2	n.a.	0.8	4.8	-106 at 1 MHz	-180
[19]	CMOS 0.13	4.91	15	0.8	3.2	-112 at 1 MHz	-181
This work	CMOS 0.13	15	7.35	1.2	11	-106 at 1 MHz	-178

design a PLL for the realization of silicon monolithic DVBS satellite receivers, that nowadays were demonstrated only using bipolar or SiGe technologies.

In particular, the fact that the demonstrated VCO is an I/Q VCO allows for the conclusion that a DVBS receiver could be fabricated with a direct-conversion architecture implemented in a bulk 130 nm CMOS technology, which would be a product completely new with respect to a traditional superheterodyne one (e.g. a SiGe BiCMOS LNB cascaded with the low-voltage CMOS IF tuner).

Eventually, it has to be pointed out that in the final design of the PLL a QVCO topology exhibiting a switched capacitor bank will help with addressing the tuning range specifications.

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